



**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**In re Application of:**

Pan et al.

**Serial No.:** 09/073,494

**Filed:** May 6, 1998

**For:** TECHNIQUE FOR ELIMINATION  
OF PITTING ON SILICON SUBSTRATE  
DURING GATE STACK ETCH

**Confirmation No.:** 9834

**Examiner:** H. Vu

**Group Art Unit:** 2811

**Attorney Docket No.:** 2915.1US  
(96-149.01)

**CERTIFICATE OF MAILING**

I hereby certify that this correspondence along with any attachments referred to or identified as being attached or enclosed is being deposited with the United States Postal Service as First Class Mail (under 37 C.F.R. § 1.8(a)) on the date of deposit shown below with sufficient postage and in an envelope addressed to the Commissioner for Patents, Washington, D.C. 20231.

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Amanda Holland

Typed/printed name of person whose signature is contained above

**AMENDMENT**

Commissioner for Patents  
Washington, D.C. 20231

Sir:

The following amendments and remarks are filed in response to the Examiner's remarks in the Office Action mailed October 24, 2002, the three-month shortened statutory period for response to which expired on January 24, 2003. Enclosed herewith is a Petition for One-Month Extension of Time and accompanying fee under 37 C.F.R. § 1.17(a)(1).

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